

Status report #9

2019. 12. 24 (Tue)

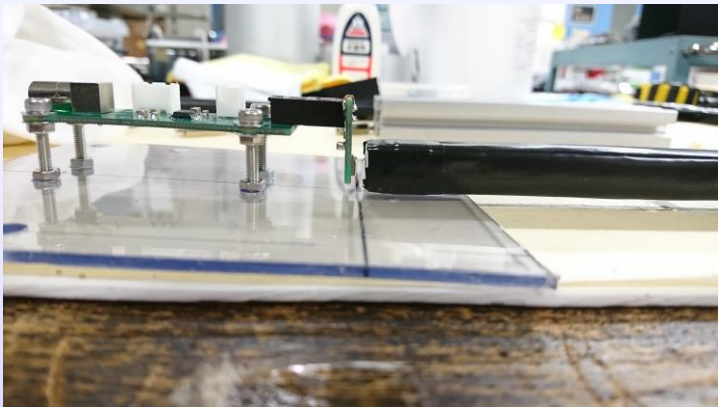
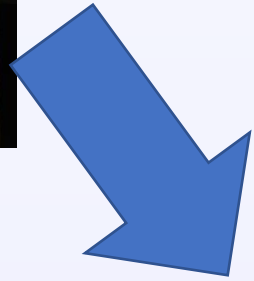
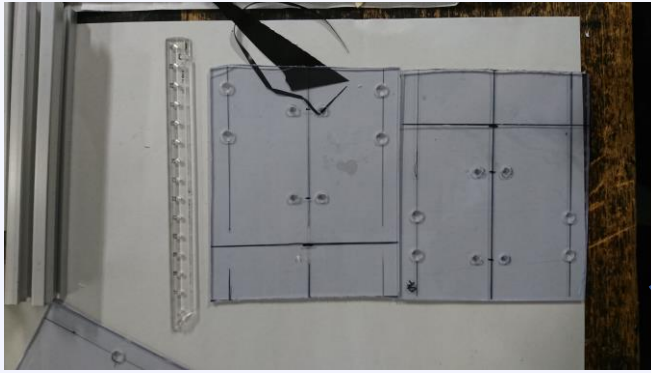
B4 T. FUJIWARA

- Beam time at ELPH
 - Preparation new ToF counter
 - Rough result

New ToF counter

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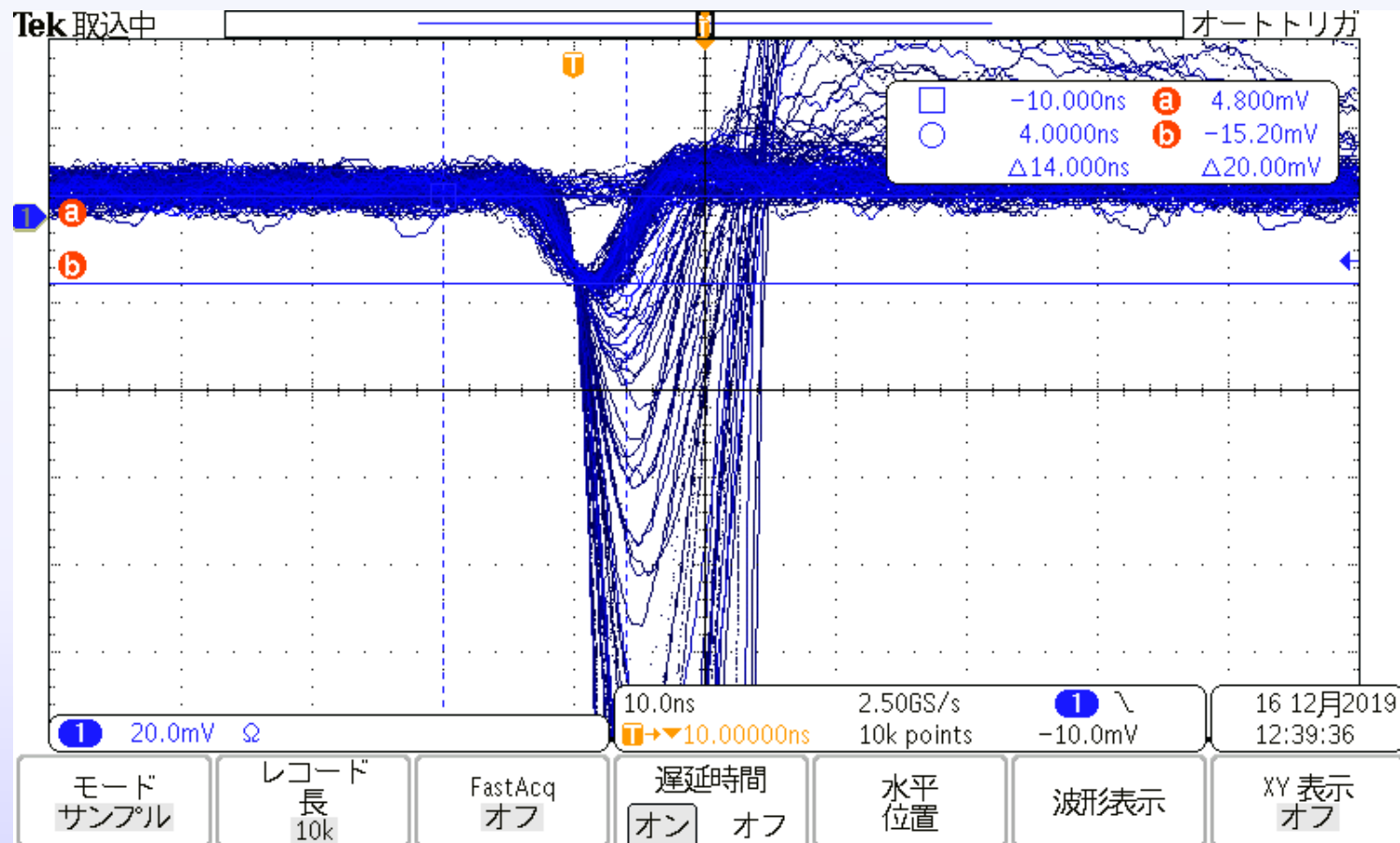
- Making the frame for setting ToF counter with acrylic board & aluminum frame



Signal of new TOF counters

3

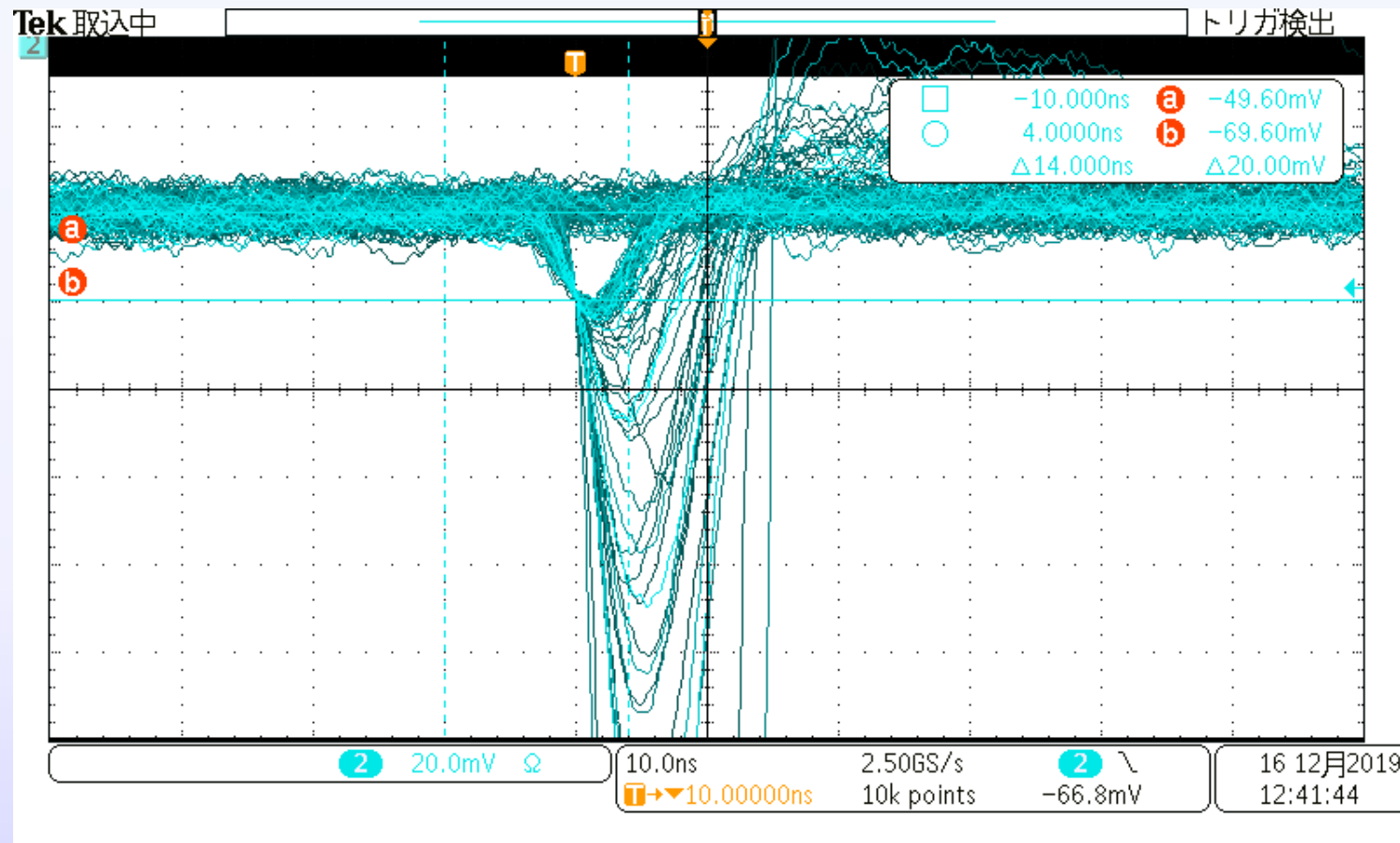
- ベータ線源無, PMamp + 印加電圧: $V=44.7\text{V}(=V_{op} + 3.0\text{V})$ でのsignal
- TOF-R R1



Signal of new TOF counters

4

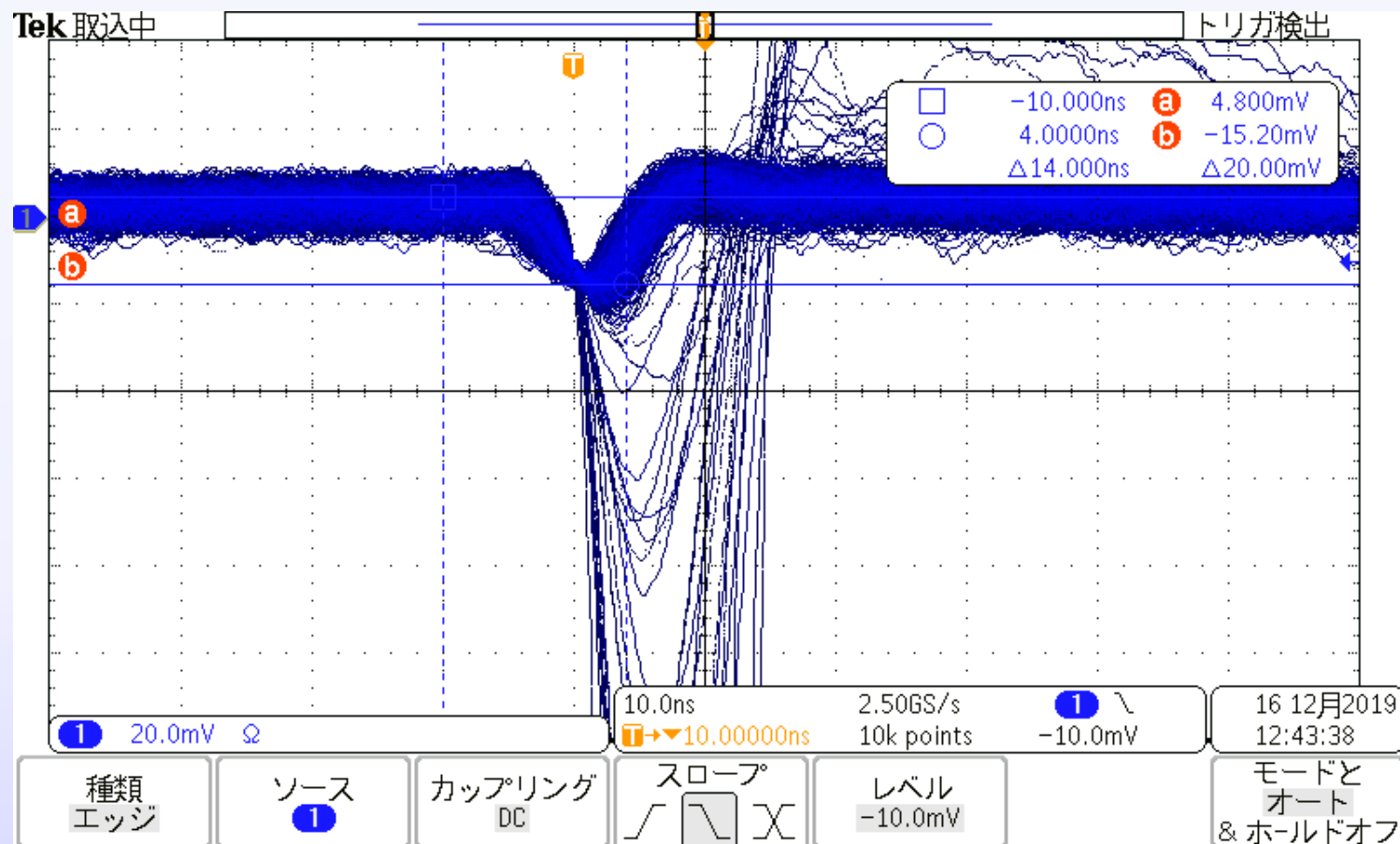
- ベータ線源無, PMamp + 印加電圧: $V=44.7\text{V}(=V_{op} + 3.0\text{V})$ でのsignal
- TOF-R R2



Signal of new TOF counters

5

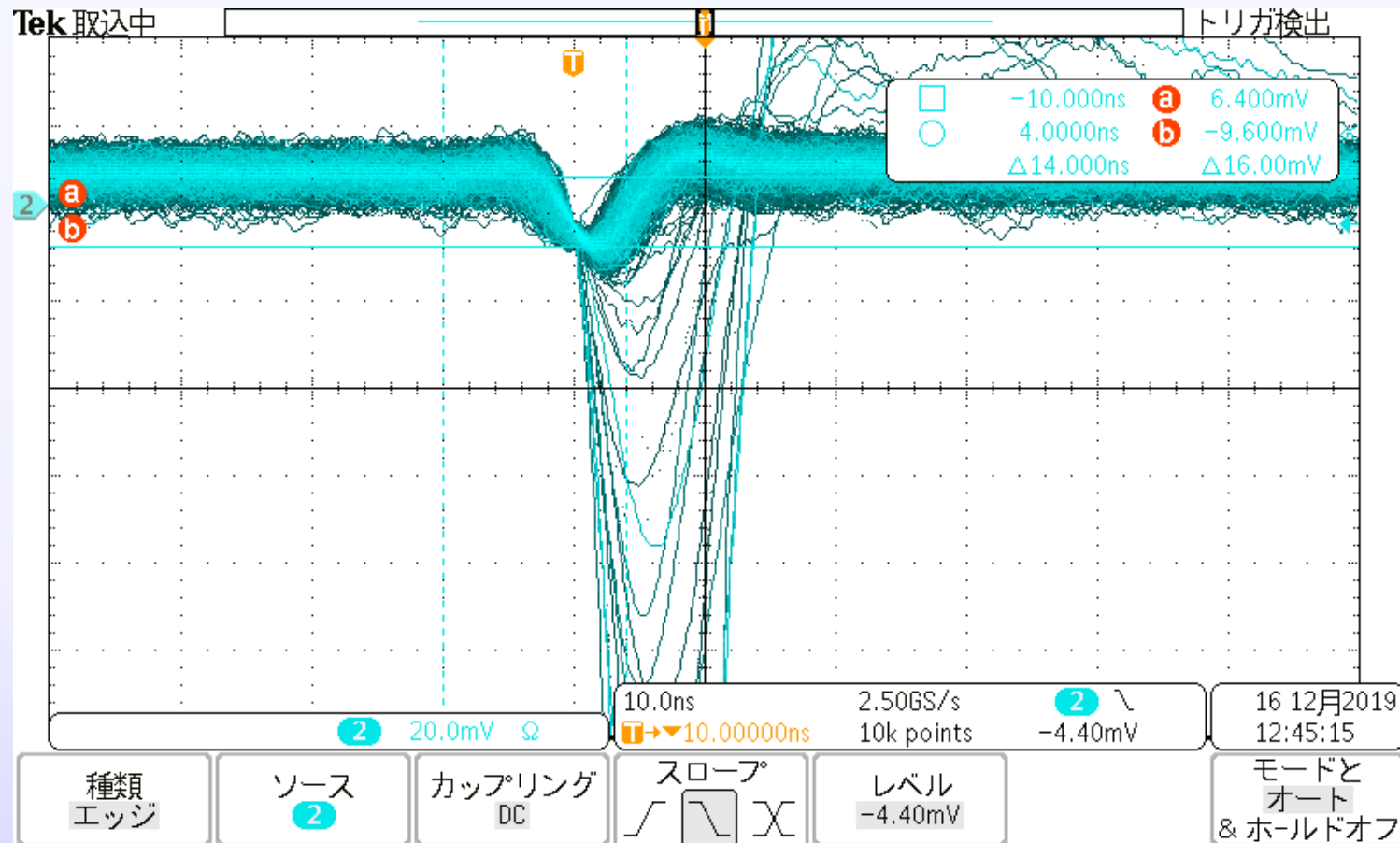
- ベータ線源無, PMamp + 印加電圧: $V=44.7\text{V}(=V_{op} + 3.0\text{V})$ でのsignal
- TOF-L L1



Signal of new TOF counters

6

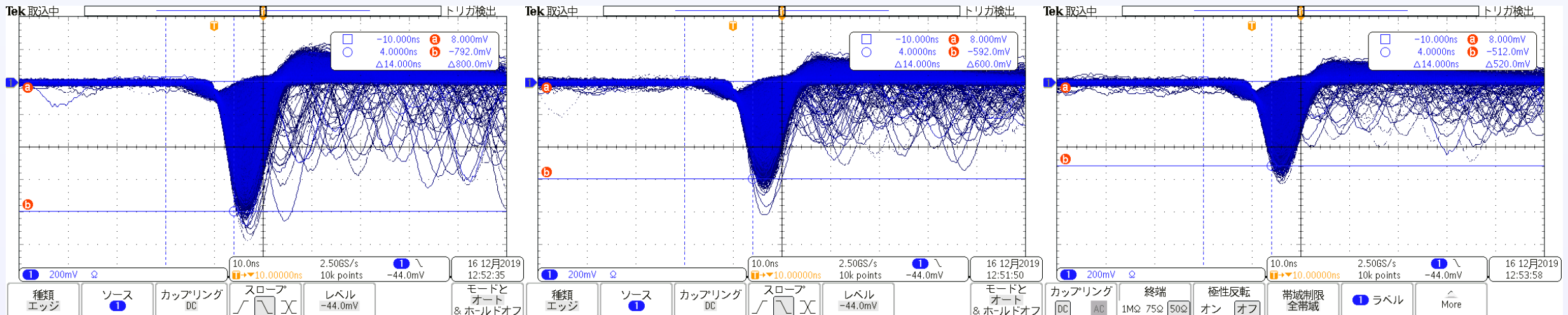
- ベータ線源無, PMamp + 印加電圧: $V=44.7\text{V}(=V_{op} + 3.0\text{V})$ でのsignal
- TOF-L L2



Signal of new TOF counters -1-

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- ベータ線源有, PMamp + 印加電圧: $V=44.7\text{V}(=V_{op} + 3.0\text{V})$ でのMIP
- TOF-R R1

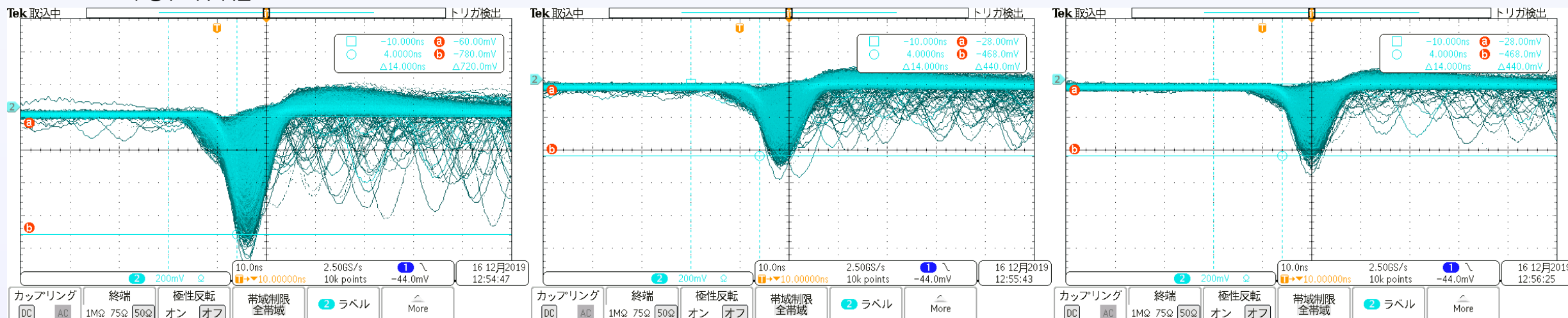


位置	pulse height [mV]
center	600
near	800
far	500

Signal of new TOF counters -2-

8

- ベータ線源有, PMamp + 印加電圧: $V=44.7\text{V}(=V_{op} + 3.0\text{V})$ でのMIP
- TOF-R R2

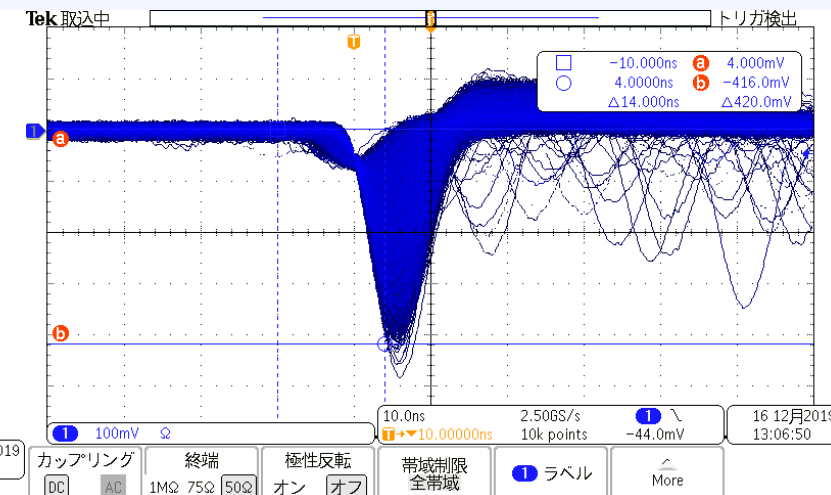
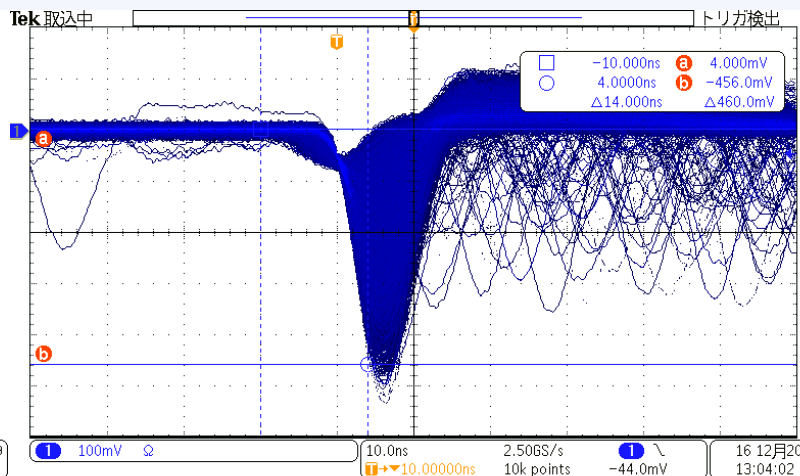
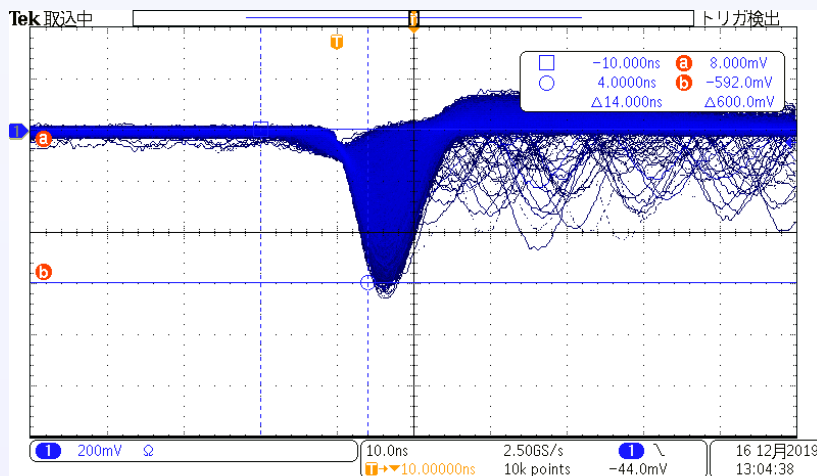


位置	pulse height [mV]
center	450
near	700
far	400

Signal of new TOF counters -3-

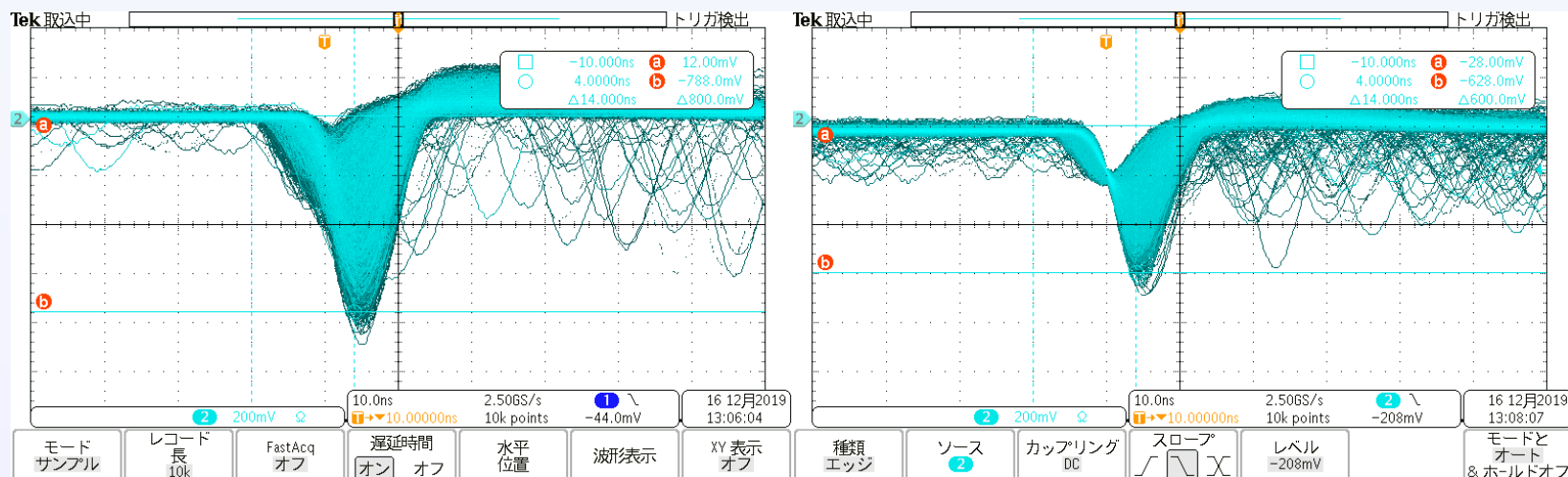
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- ベータ線源有, PMamp + 印加電圧: $V=44.7\text{V}(=V_{op} + 3.0\text{V})$ でのMIP
- TOF-L L1



位置	pulse height [mV]
center	450
near	600
far	400

- ベータ線源有, PMamp + 印加電圧: $V=44.7\text{V}(=V_{op} + 3.0\text{V})$ でのMIP
- TOF-L L2

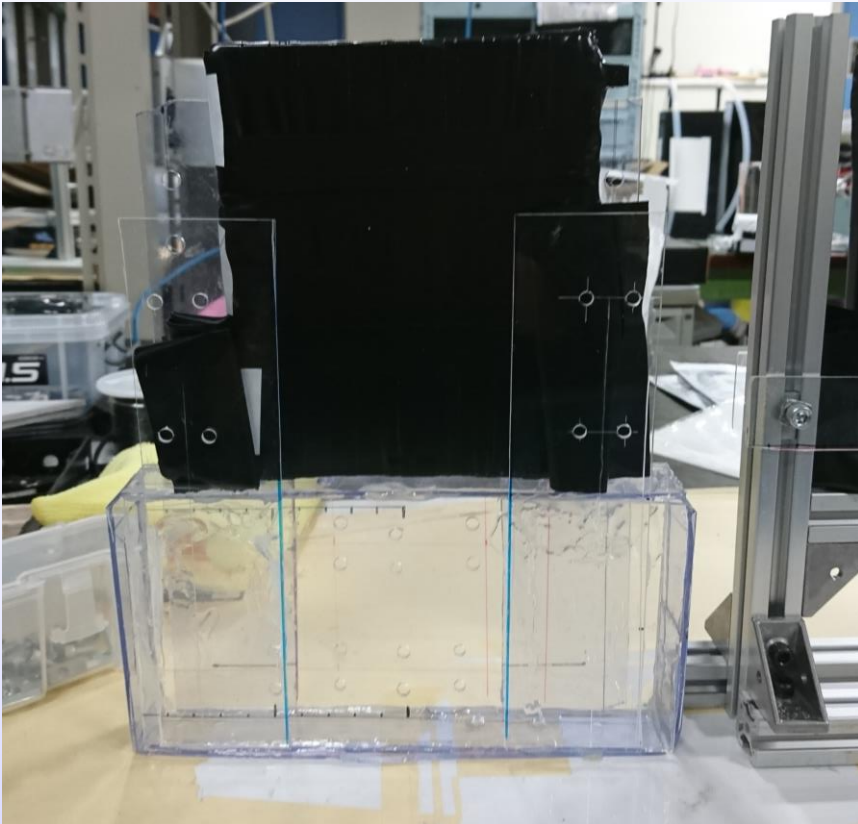


位置	pulse height [mV]
center	600
near	800
far	500

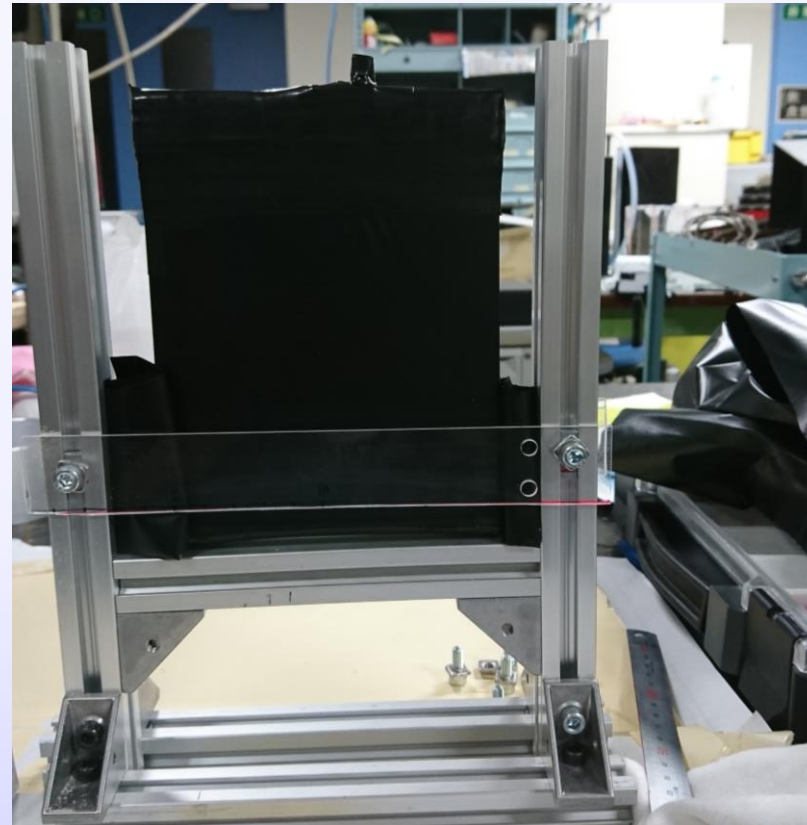
Making T1s & T2 frame

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- T1 : acrylic board, use only ~3cm length direction of beam
- T2: aluminum frame ~5cm



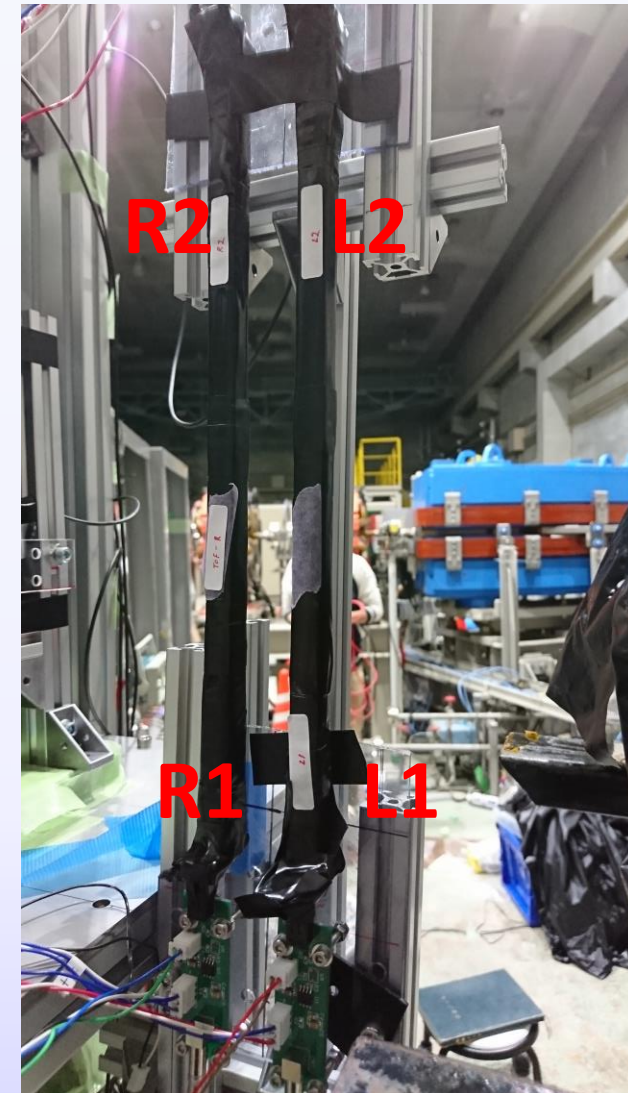
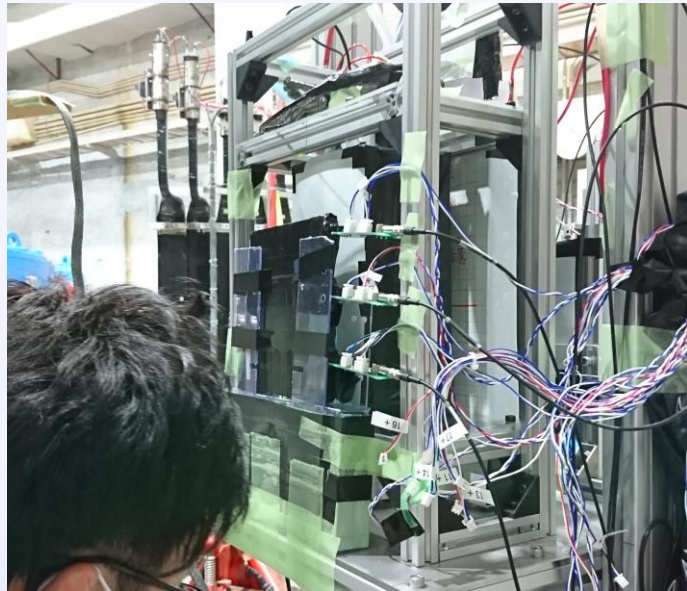
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ELS status #9

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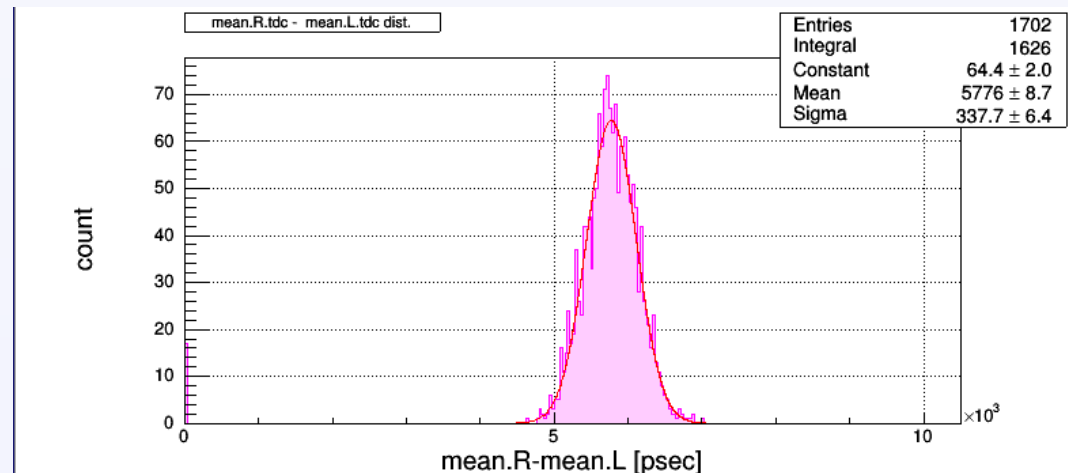
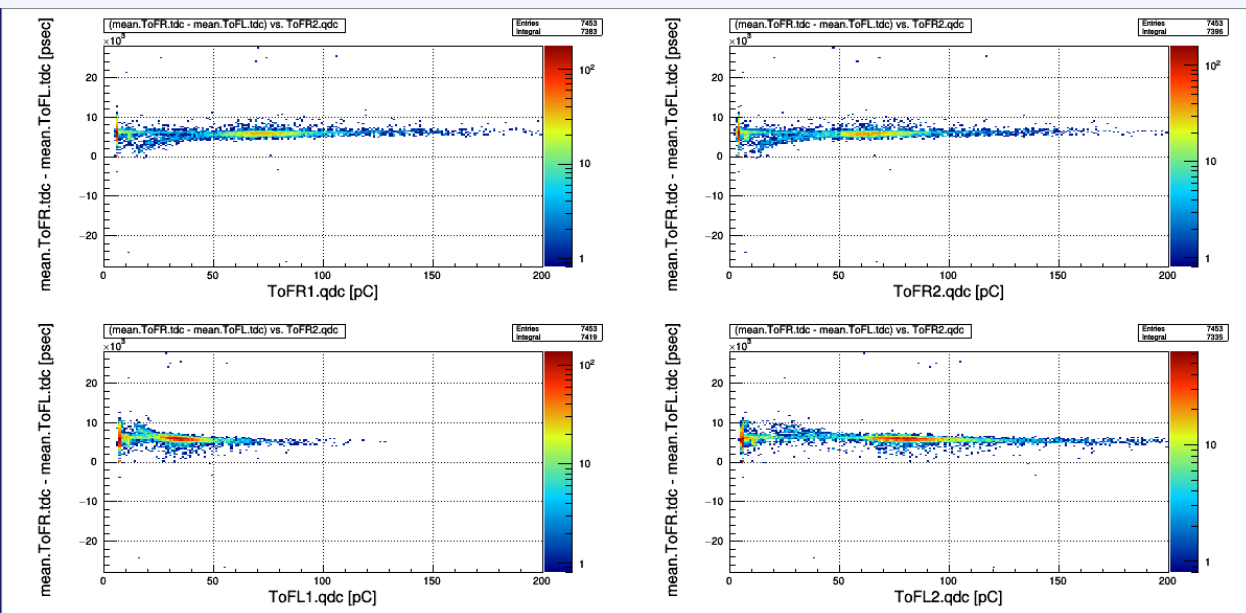
- Setting on the frame with other detectors



- Study bias voltage and threshold dependence
- bias voltage: 41.7, 43.2, 43.7, 44.7, 45.7, 46.2, 47.7, 49.2, (49.7, 50.7, 51.7, 52.7, 53.7, 55.2, 56.7)
- threshold: about $\sim -30\text{mV}$, $\sim -50\text{mV}(\text{initial} + 20)$, $\sim -100\text{mV}(\text{initial} + 70)$, $\sim -150\text{mV}(\text{initial} + 120)$
 - Initial value [mV]: R1 : -31.4, R2: -25.0, L1: -24.5, L2: -34.7
- Total : 45 points taking

- Sorry but I have only rough result...
(forget copying figure from ELPH machine to my pc...)

For example: run0123(V=44.7, threshold ~ -50 mV)



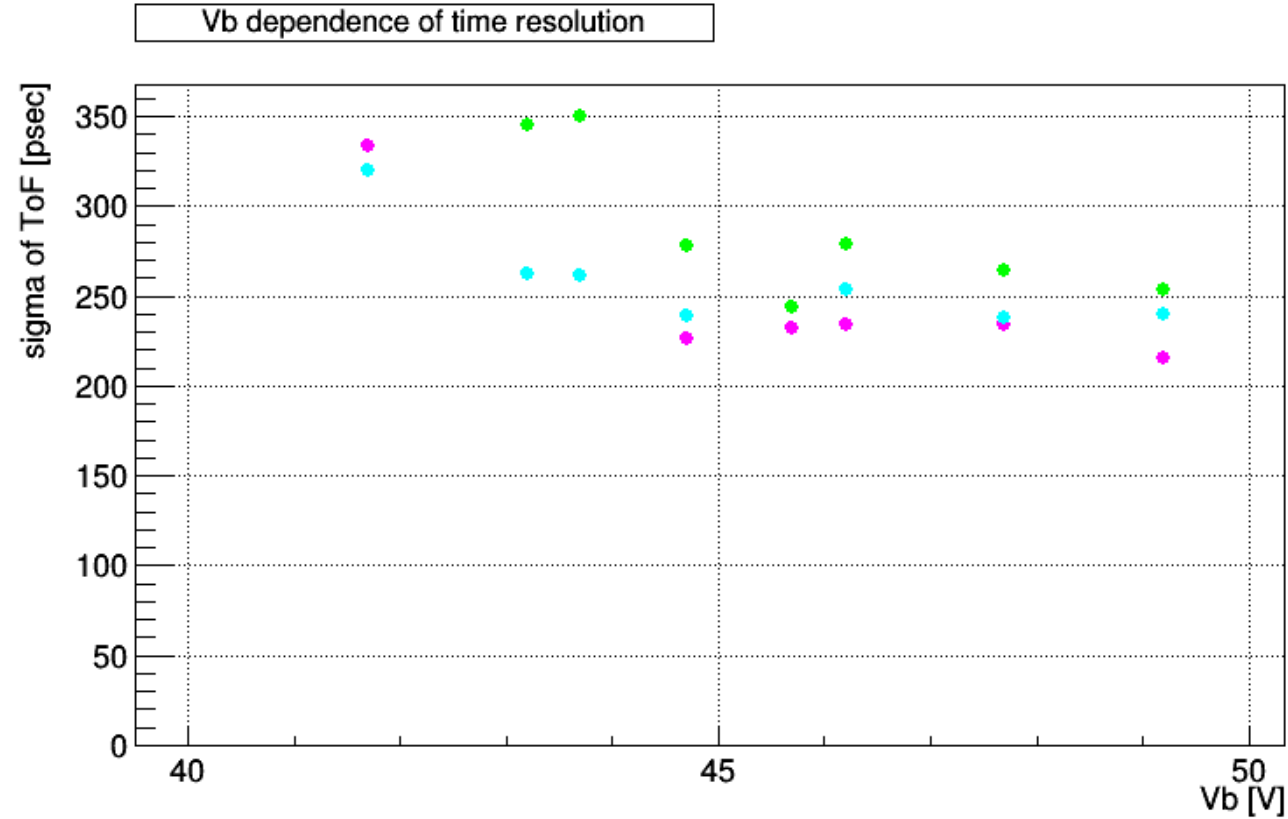
run0123

$V_b = 44.7$

cut condition [ch]: $650 < R1.qdc < 810$, $280 < L1.qdc < 400$

$\sigma_{\text{detector}} = 239$

- HV dependence



- Data analysis → より詳細に...(time walk correction, event selection)
- (Preparation for hyper nuclear seminar)

皆様, 良いお年を...
Have a good year...